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(54) **ORGANIC LIGHT-EMITTING DISPLAY DEVICE AND METHOD FOR FABRICATING THE SAME**

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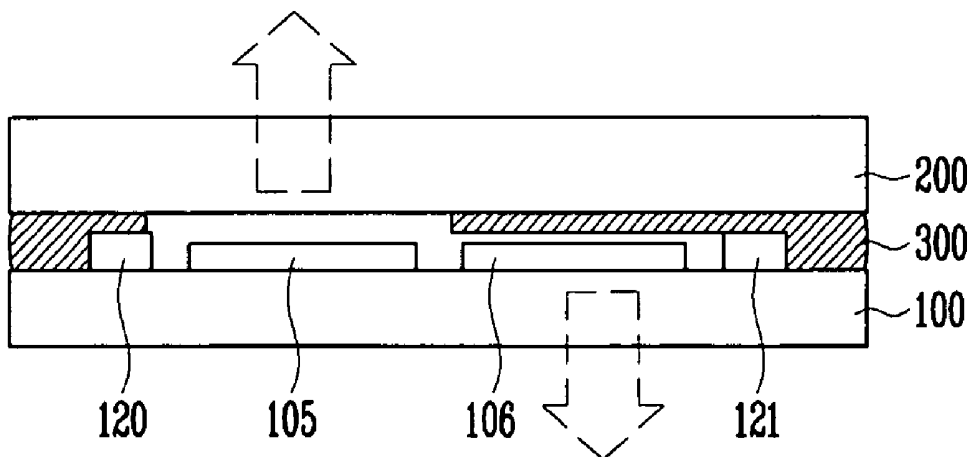
(51) **Int. Cl.**
H01L 27/02 (2006.01)
H01L 27/12 (2006.01)
(52) **U.S. Cl.** 313/512; 313/498; 257/79; 257/81; 257/98
(58) **Field of Classification Search** 313/512, 313/498; 257/79, 81, 98
See application file for complete search history.

(57) **ABSTRACT**

Disclosed is an organic light-emitting display device capable of blocking the infiltration of oxygen and moisture and effectively preventing light leakage. The device includes a first substrate with first and second pixel regions wherein a plurality of organic light-emitting diodes are formed. The device further includes a non-pixel region around the first and the second pixel-regions, a second substrate disposed on the upper part of the first substrate to be overlapped with the first and the second pixel regions and a part of the non-pixel region, and a frit provided between the first and the second substrates to be overlapped with at least one of the first and the second pixel regions and at least a part of the non-pixel region. The first and the second substrates are adhered to each other by the fit in the part corresponding to the non-pixel region.

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23 Claims, 6 Drawing Sheets



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Page 2

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FIG. 1
(PRIOR ART)

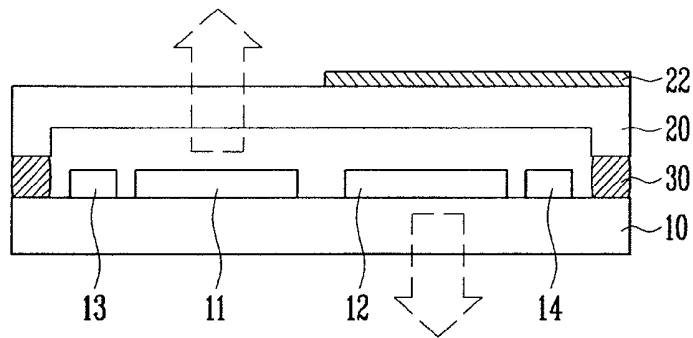


FIG. 2

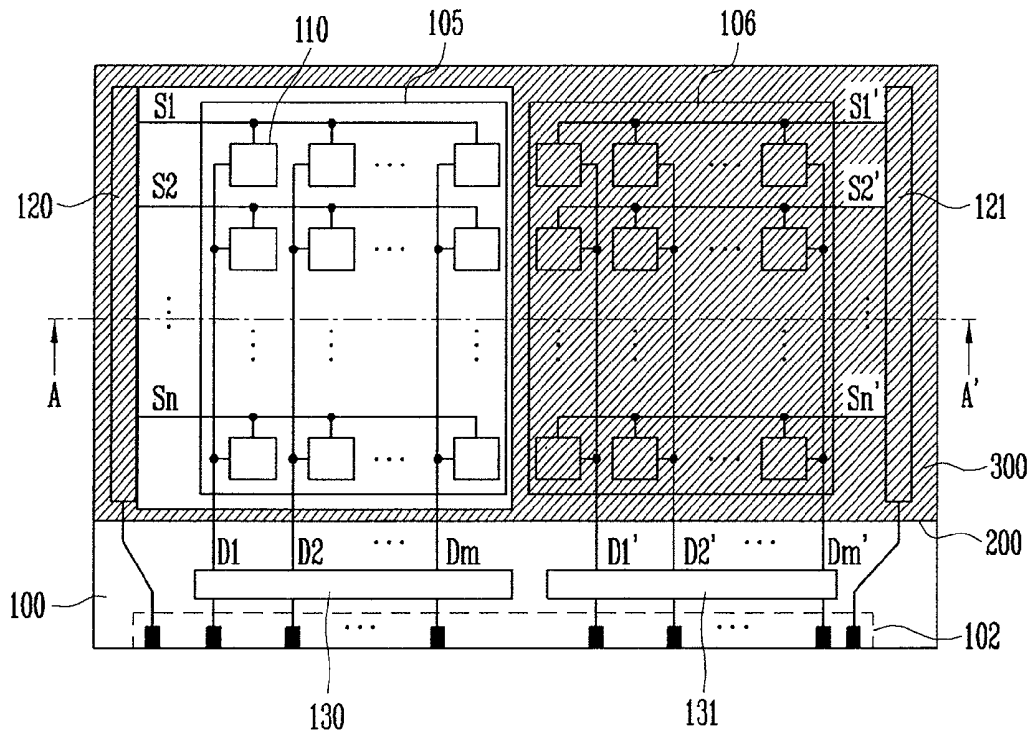


FIG. 3

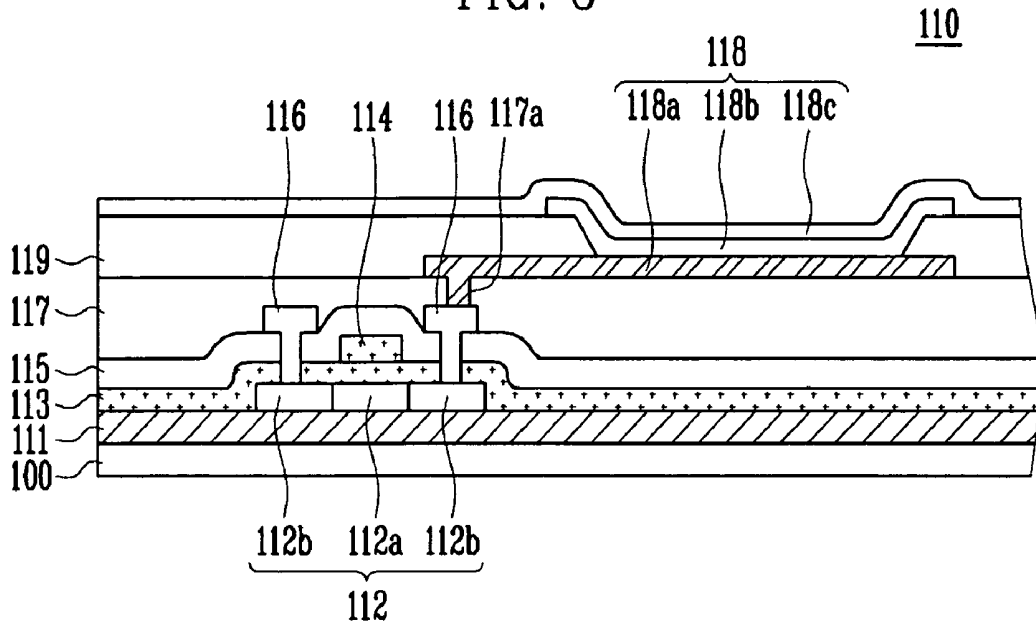


FIG. 4

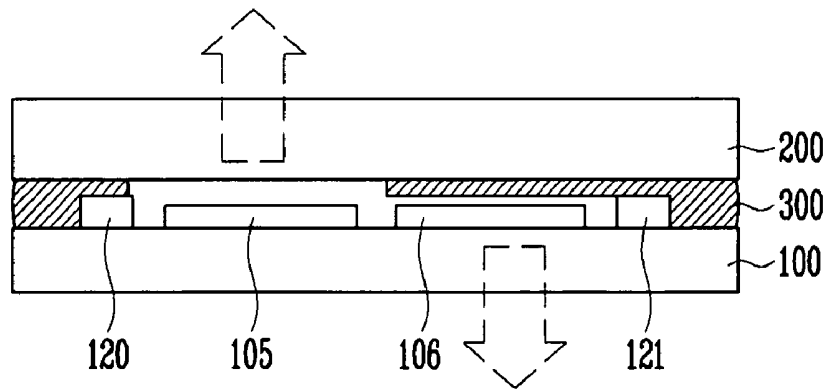


FIG. 5

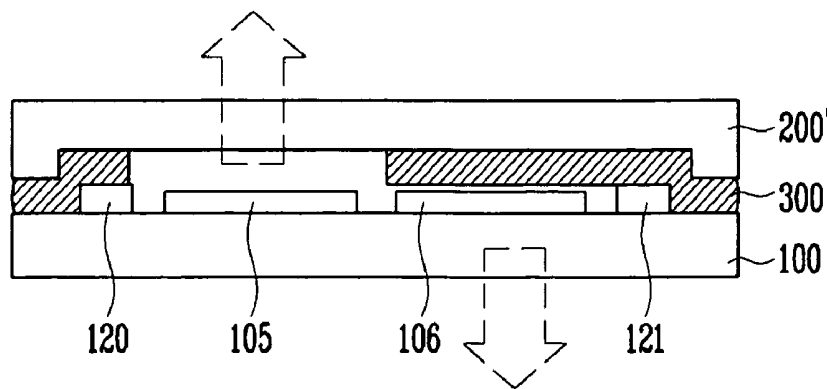


FIG. 6a

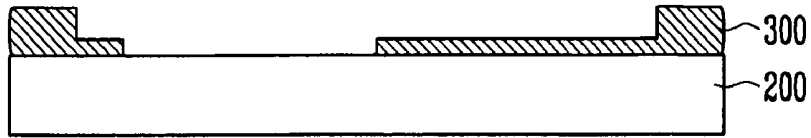


FIG. 6b

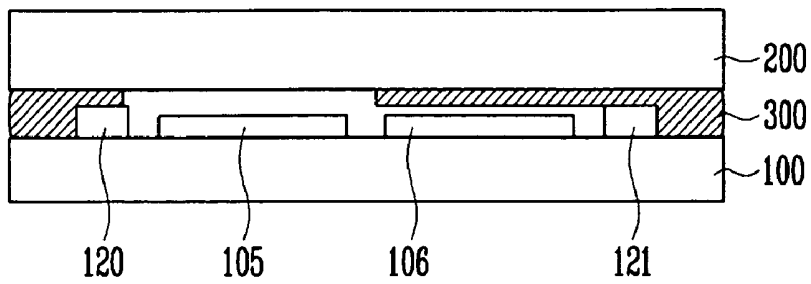


FIG. 6c

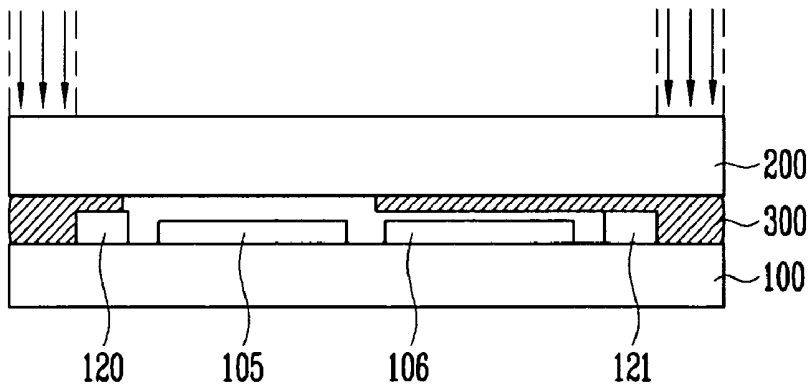


FIG. 6d

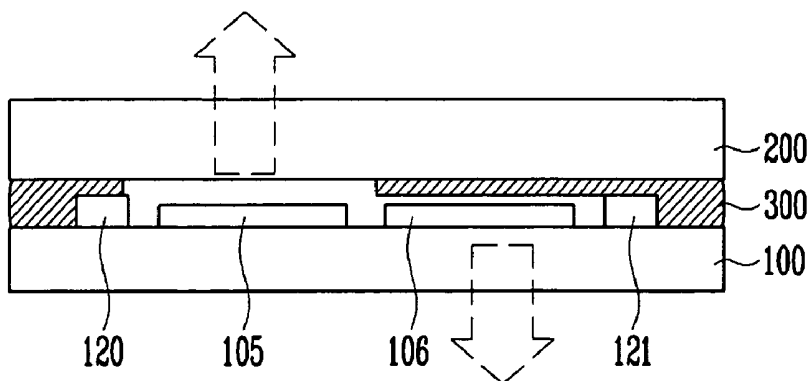


FIG. 7A

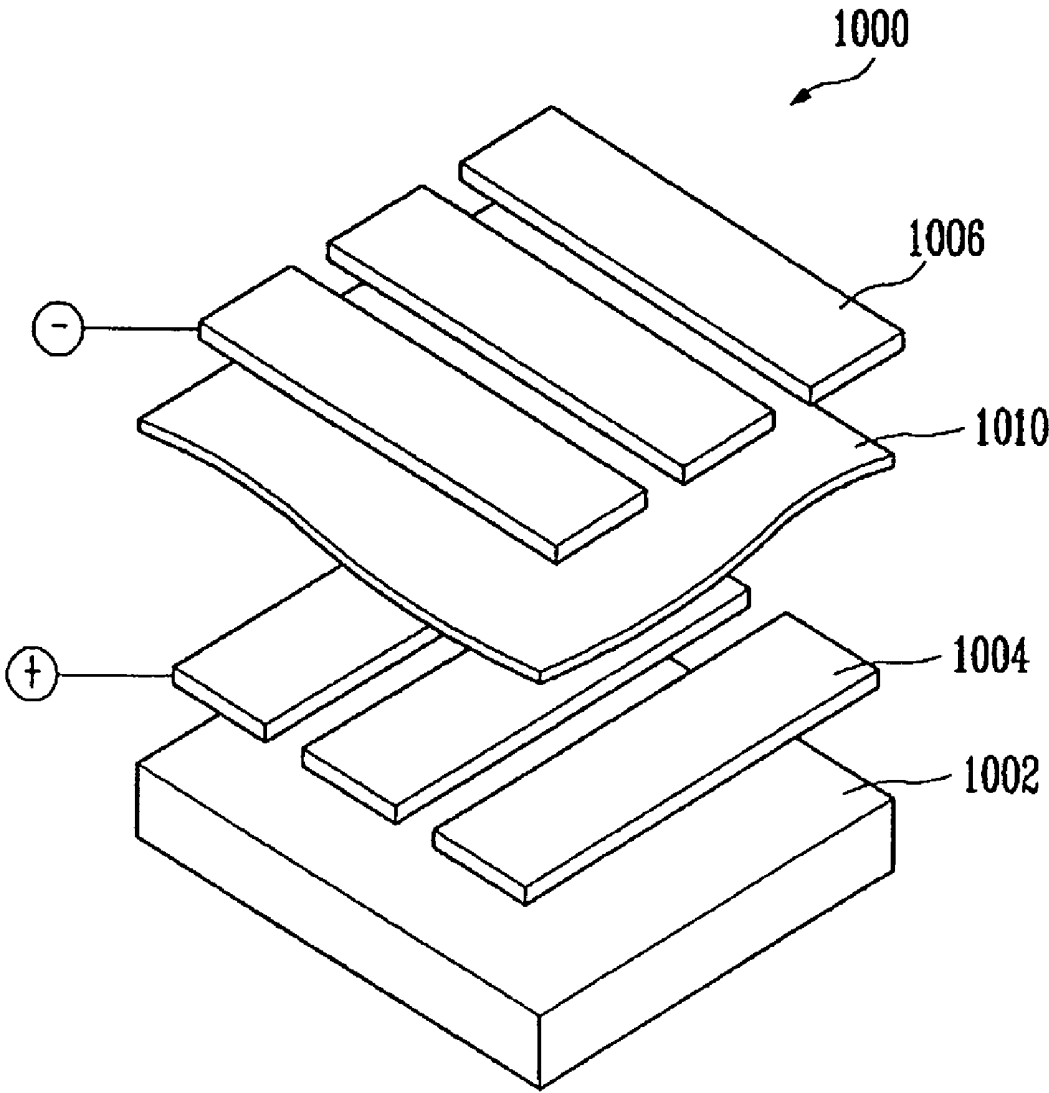


FIG. 7B

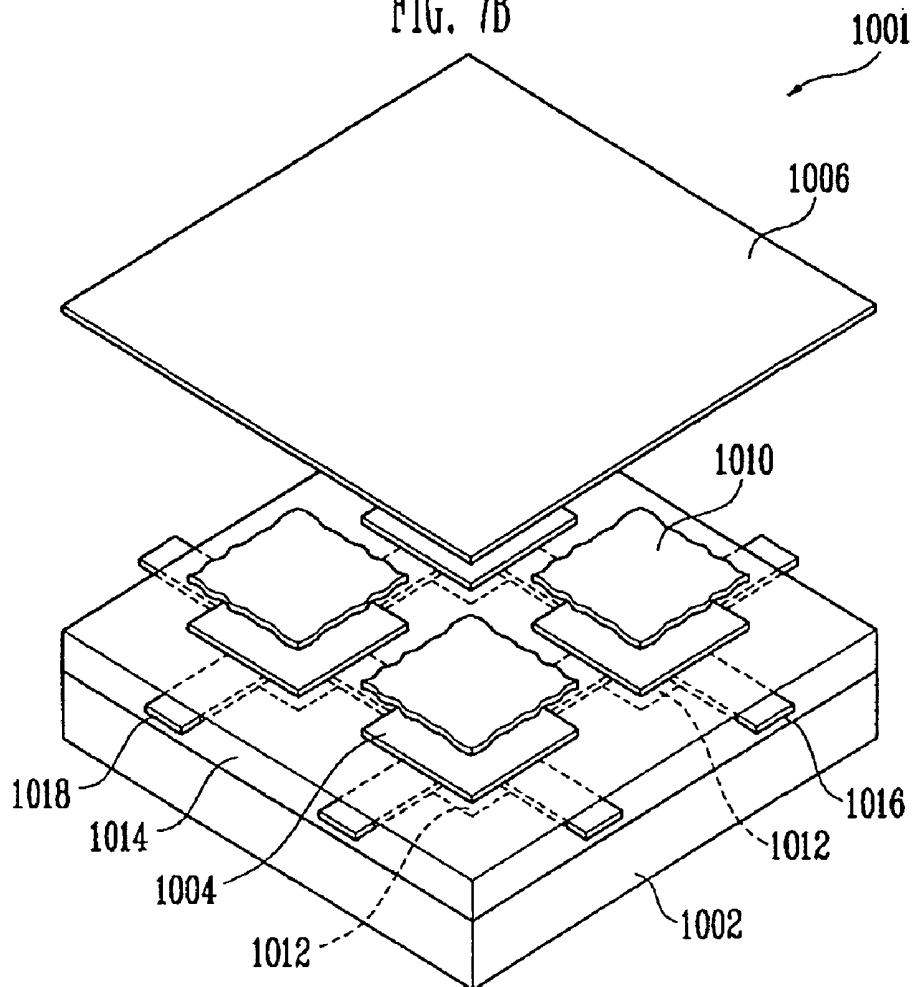


FIG. 7C

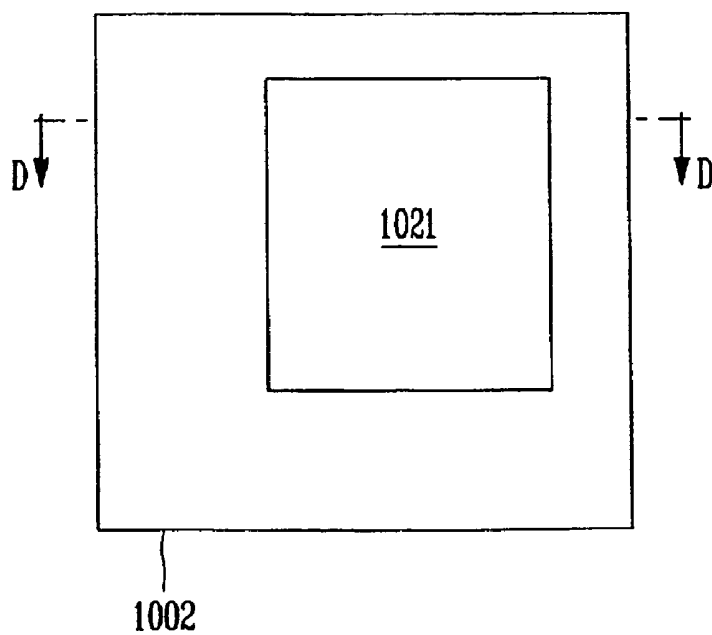


FIG. 7D

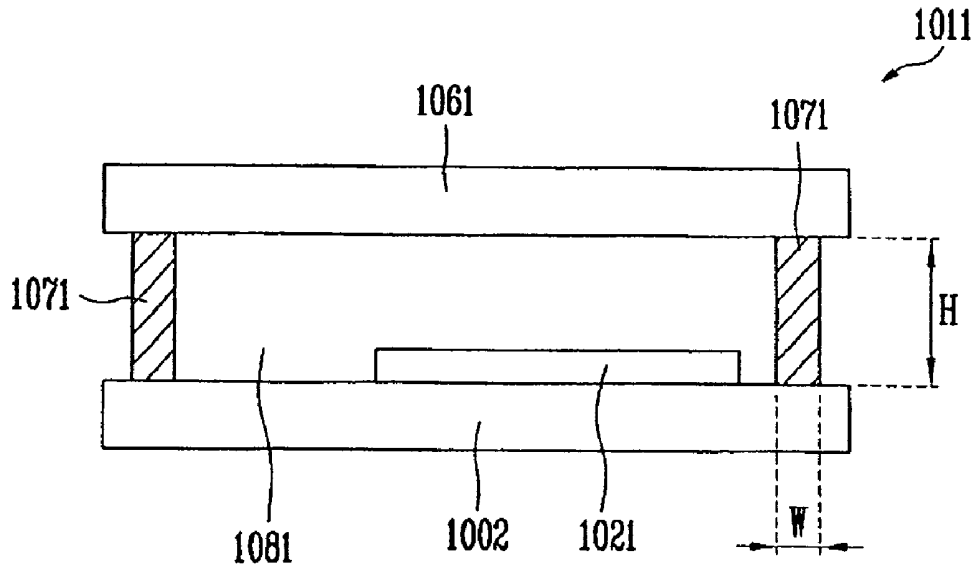
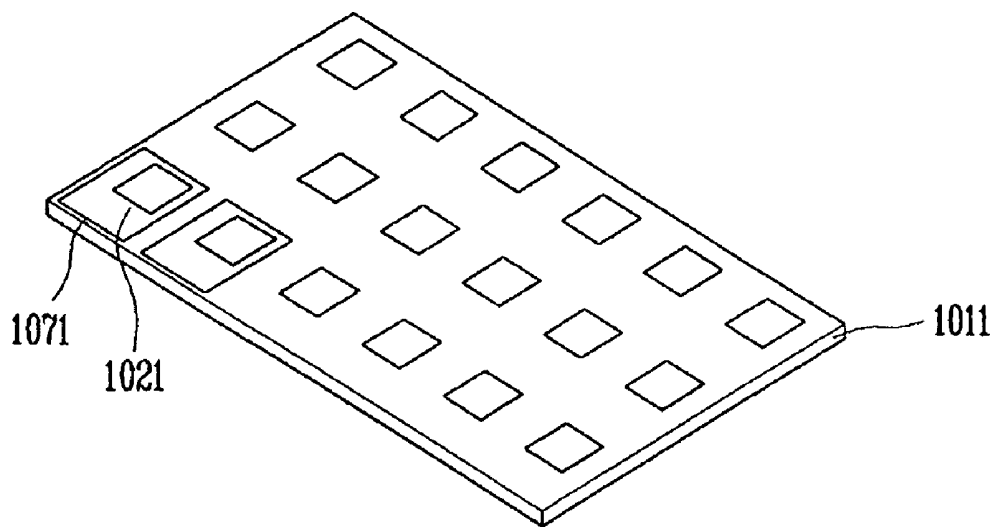


FIG. 7E



**ORGANIC LIGHT-EMITTING DISPLAY
DEVICE AND METHOD FOR FABRICATING
THE SAME**

CROSS-REFERENCE TO RELATED
APPLICATIONS

This application claims the benefit of Korean Patent Application No. 2006-0008762, filed on Jan. 27, 2006, in the Korean Intellectual Property Office, the disclosure of which is incorporated herein by reference.

BACKGROUND OF THE INVENTION

1. Field of the Invention

The present invention relates to an organic light-emitting display device and method for fabricating the same. More particularly, the invention relates to an organic light-emitting display device and method for fabricating the same, capable of blocking the infiltration of oxygen and moisture, etc. by encapsulating a first and a second substrates with a frit, simplifying the process and effectively preventing light leakage.

2. Description of the Related Art

An organic light-emitting display device is one sort of a flat display devices wherein an organic light-emitting layer is positioned between electrodes opposed to each other and voltage is then applied between the electrodes so that holes and electrons injected from the respective electrodes to the organic light-emitting layer are coupled, and the exciting molecules thus generated are returned to a base state, thereby emitting energy as light.

The organic light-emitting display device is excellent in terms of light-emitting efficiency, brightness, viewing angle and response speed and can be fabricated to be light weight and thin and therefore, has been spotlighted as a next generation display.

The organic light-emitting display device can include a pair of substrates joined together by a material, e.g., a glass frit, which seals the substrates together to protect the materials from exposure to moisture and/or other contaminants. One of the substrates may be a transparent substrate through which the organic light-emitting display device can be viewed while the other may be non-transparent, preferably comprising a black matrix to prevent light leakage from interfering with the light emitted by the pixels.

The frit can comprise a black absorbing tint in order to block light and function as a black matrix, BM, thereby preventing light leakage. Light leakage is a phenomenon due to the reflection of light generated external to the display region, such as light scattered toward the back substrate and transmitting through the back substrate, or light generated from a second display region and reflecting off the back substrate. Image quality can be deteriorated when light leakage is generated. However, the frit is typically applied to only the outer edge of the display region to be encapsulated, that is, the part on which an organic light-emitting pixel element is not formed. Thus, the frit is ineffective in functioning as a black matrix to block light coming from regions outside of the display region, such as, transmitting from behind the back substrate or reflecting from a second display region off of the back substrate. That is, since the light leakage generated from outside of the pixel region is not effectively blocked, a light shielding film covering the back substrate is typically formed or the back substrate in order to prevent light from the second pixel region from reflecting off the second substrate. Thereby,

the light leakage is not effectively prevented, causing problems that the fabricating process is complicated and the process time is extended.

Therefore, a method of blocking an infiltration of oxygen and moisture into the space between the two substrates by encapsulating the two substrates with the frit, while simplifying the process and effectively preventing light leakage is needed.

SUMMARY OF THE INVENTION

An aspect of the invention provides an organic light-emitting device. The device includes a first substrate, a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion, a first array of light-emitting pixels interposed between the first substrate and the second substrate, a second array of light-emitting pixels interposed between the first substrate and the second substrate, a frit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface, wherein the first portion generally opposes the first array, and wherein the second portion generally opposes the second array, and a frit seal interconnecting the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.

In the above described device, the pixels of the first array may be configured to emit light substantially through the first substrate. The pixels of the second array may be configured to emit light substantially through the second substrate. The first portion of the inner surface may oppose the entire first array. A portion of the frit seal may be adhered to the first substrate and the second substrate. The frit may comprise a glass material, and at least one of a filler material to adjust absorption characteristics, and a filler material to adjust thermal expansion characteristics. The first substrate and the second substrate may be transparent substrates.

Another aspect of the invention provides an organic light-emitting device. This device includes a first substrate, a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion, wherein a thickness of the second substrate in an inner portion comprising the first portion and the second portion is thinner than in an outer portion surrounding the inner portion, a first array of light-emitting pixels interposed between the first substrate and the second substrate, a second array of light-emitting pixels interposed between the first substrate and the second substrate, a frit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface, wherein the first portion generally opposes the first array, and wherein the second portion generally opposes the second array, and a frit seal formed over the outer portion interconnecting the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.

In the above described device, the frit layer formed over the first portion of the inner surface and the frit seal formed over the outer portion may be the same thickness. The first portion of the inner surface may oppose the entire first array.

Another aspect of the invention provides a method of making an organic light-emitting device. The method includes providing an unfinished device comprising a first substrate, a first array of organic light emitting pixels, and a second array

of light emitting pixels. The method further comprises providing a second substrate, a fit layer and a peripheral frit. In some embodiments, the second substrate comprises a surface comprising a first portion and a second portion, the fit layer being formed over the first portion of the surface while not being formed over the second portion of the surface, the peripheral fit surrounding the first portion and the second portion. The method further comprises placing the second substrate over the unfinished device such that the first array and the second array are interposed between the first substrate, the second substrate and the frit layer. After placing the second substrate, the peripheral frit surrounds the first array and the second array, wherein the first portion generally opposes the first array, and the second portion generally opposes the second array. The method further comprises melting and resolidifying at least part of the peripheral frit so as to interconnect the unfinished device and the second substrate via the peripheral frit.

In the above described method, the peripheral frit may be thicker than the frit layer formed over the first portion. Melting the peripheral frit may include irradiating by laser or infrared rays. The wavelength of the laser or the infrared rays may be in a range from about 800 nm to about 1200 nm. The method may further include masking at least the first portion and the second portion while irradiating. The peripheral frit may be applied to at least one of the first substrate and the second substrate in a form of a paste comprising a glass material and a filler material to adjust absorption characteristics of laser or infrared rays, and the method may further include heating the peripheral frit to a temperature sufficient to cure the frit paste. Heating the frit paste may include irradiating the frit paste with laser or infrared rays. The frit paste may be heated to a temperature in a range from about 300° C. to about 500° C. The first portion of the inner surface may oppose the entire first array.

Another aspect of the invention provides an organic light-emitting device. The device includes a first substrate, a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion, light-emitting pixels interposed between the first substrate and the second substrate, a frit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface, and a frit seal interconnecting the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.

In the above described device, the light-emitting pixels may include a first array and a second array. The first array may be configured to emit light through the first substrate. The second array may be configured to emit light through the second substrate. The first portion may generally oppose the first array, and the second portion may generally oppose the second array.

BRIEF DESCRIPTION OF THE DRAWINGS

These and/or other aspects and advantages of the invention will become apparent and more readily appreciated from the following description of the preferred embodiments, taken in conjunction with the accompanying drawings of which:

FIG. 1 is a cross-sectional view of a general organic light-emitting display device.

FIG. 2 is a plan view of an organic light-emitting display device according to the embodiment of the present invention.

FIG. 3 is a cross-sectional view of main parts of the pixel shown in FIG. 2.

FIG. 4 and FIG. 5 are cross-sectional views of an organic light-emitting display device taken along A-A' line in FIG. 2.

FIG. 6a to FIG. 6d are cross-sectional views showing the fabricating process of the organic light-emitting display device shown in FIG. 4.

FIG. 7A is a schematic exploded view of a passive matrix type organic light emitting display device in accordance with one embodiment.

FIG. 7B is a schematic exploded view of an active matrix type organic light emitting display device in accordance with one embodiment.

FIG. 7C is a schematic top plan view of an organic light emitting display in accordance with one embodiment.

FIG. 7D is a cross-sectional view of the organic light emitting display of FIG. 7C, taken along the line d-d.

FIG. 7E is a schematic perspective view illustrating mass production of organic light emitting devices in accordance with one embodiment.

DETAILED DESCRIPTION OF PREFERRED EMBODIMENTS

Hereinafter, preferred embodiments of the present invention, proposed so that a person having ordinary skill in the art can easily carry out the present invention, will be described in a more detailed manner with reference to the accompanying FIG. 2 to FIG. 6d.

An organic light emitting display (OLED) is a display device comprising an array of organic light emitting diodes. Organic light emitting diodes are solid state devices which include an organic material and are adapted to generate and emit light when appropriate electrical potentials are applied.

OLEDs can be generally grouped into two basic types dependent on the arrangement with which the stimulating electrical current is provided. FIG. 7A schematically illustrates an exploded view of a simplified structure of a passive matrix type OLED 1000. FIG. 7B schematically illustrates a simplified structure of an active matrix type OLED 1001. In both configurations, the OLED 1000, 1001 includes OLED pixels built over a substrate 1002, and the OLED pixels include an anode 1004, a cathode 1006 and an organic layer 1010. When an appropriate electrical current is applied to the anode 1004, electric current flows through the pixels and visible light is emitted from the organic layer.

Referring to FIG. 7A, the passive matrix OLED (PMOLED) design includes elongate strips of anode 1004 arranged generally perpendicular to elongate strips of cathode 1006 with organic layers interposed therebetween. The intersections of the strips of cathode 1006 and anode 1004 define individual OLED pixels where light is generated and emitted upon appropriate excitation of the corresponding strips of anode 1004 and cathode 1006. PMOLEDs provide the advantage of relatively simple fabrication.

Referring to FIG. 7B, the active matrix OLED (AMOLED) includes driving circuits 1012 arranged between the substrate 1002 and an array of OLED pixels. An individual pixel of AMOLEDs is defined between the common cathode 1006 and an anode 1004, which is electrically isolated from other anodes. Each driving circuit 1012 is coupled with an anode 1004 of the OLED pixels and further coupled with a data line 1016 and a scan line 1018. In embodiments, the scan lines 1018 supply scan signals that select rows of the driving circuits, and the data lines 1016 supply data signals for particular driving circuits. The data signals and scan signals stimulate the local driving circuits 1012, which excite the anodes 1004 so as to emit light from their corresponding pixels.

In the illustrated AMOLED, the local driving circuits **1012**, the data lines **1016** and scan lines **1018** are buried in a planarization layer **1014**, which is interposed between the pixel array and the substrate **1002**. The planarization layer **1014** provides a planar top surface on which the organic light emitting pixel array is formed. The planarization layer **1014** may be formed of organic or inorganic materials, and formed of two or more layers although shown as a single layer. The local driving circuits **1012** are typically formed with thin film transistors (TFT) and arranged in a grid or array under the OLED pixel array. The local driving circuits **1012** may be at least partly made of organic materials, including organic TFT. AMOLEDs have the advantage of fast response time improving their desirability for use in displaying data signals. Also, AMOLEDs have the advantages of consuming less power than passive matrix OLEDs.

Referring to common features of the PMOLED and AMOLED designs, the substrate **1002** provides structural support for the OLED pixels and circuits. In various embodiments, the substrate **1002** can comprise rigid or flexible materials as well as opaque or transparent materials, such as plastic, glass, and/or foil. As noted above, each OLED pixel or diode is formed with the anode **1004**, cathode **1006** and organic layer **1010** interposed therebetween. When an appropriate electrical current is applied to the anode **1004**, the cathode **1006** injects electrons and the anode **1004** injects holes. In certain embodiments, the anode **1004** and cathode **1006** are inverted; i.e., the cathode is formed on the substrate **1002** and the anode is oppositely arranged.

Interposed between the cathode **1006** and anode **1004** are one or more organic layers. More specifically, at least one emissive or light emitting layer is interposed between the cathode **1006** and anode **1004**. The light emitting layer may comprise one or more light emitting organic compounds. Typically, the light emitting layer is configured to emit visible light in a single color such as blue, green, red or white. In the illustrated embodiment, one organic layer **1010** is formed between the cathode **1006** and anode **1004** and acts as a light emitting layer. Additional layers, which can be formed between the anode **1004** and cathode **1006**, can include a hole transporting layer, a hole injection layer, an electron transporting layer and an electron injection layer.

Hole transporting and/or injection layers can be interposed between the light emitting layer **1010** and the anode **1004**. Electron transporting and/or injecting layers can be interposed between the cathode **1006** and the light emitting layer **1010**. The electron injection layer facilitates injection of electrons from the cathode **1006** toward the light emitting layer **1010** by reducing the work function for injecting electrons from the cathode **1006**. Similarly, the hole injection layer facilitates injection of holes from the anode **1004** toward the light emitting layer **1010**. The hole and electron transporting layers facilitate movement of the carriers injected from the respective electrodes toward the light emitting layer.

In some embodiments, a single layer may serve both electron injection and transportation functions or both hole injection and transportation functions. In some embodiments, one or more of these layers are lacking. In some embodiments, one or more organic layers are doped with one or more materials that help injection and/or transportation of the carriers. In embodiments where only one organic layer is formed between the cathode and anode, the organic layer may include not only an organic light emitting compound but also certain functional materials that help injection or transportation of carriers within that layer.

There are numerous organic materials that have been developed for use in these layers including the light emitting

layer. Also, numerous other organic materials for use in these layers are being developed. In some embodiments, these organic materials may be macromolecules including oligomers and polymers. In some embodiments, the organic materials for these layers may be relatively small molecules. The skilled artisan will be able to select appropriate materials for each of these layers in view of the desired functions of the individual layers and the materials for the neighboring layers in particular designs.

In operation, an electrical circuit provides appropriate potential between the cathode **1006** and anode **1004**. This results in an electrical current flowing from the anode **1004** to the cathode **1006** via the interposed organic layer(s). In one embodiment, the cathode **1006** provides electrons to the adjacent organic layer **1010**. The anode **1004** injects holes to the organic layer **1010**. The holes and electrons recombine in the organic layer **1010** and generate energy particles called "excitons." The excitons transfer their energy to the organic light emitting material in the organic layer **1010**, and the energy is used to emit visible light from the organic light emitting material. The spectral characteristics of light generated and emitted by the OLED **1000**, **1001** depend on the nature and composition of organic molecules in the organic layer(s). The composition of the one or more organic layers can be selected to suit the needs of a particular application by one of ordinary skill in the art.

OLED devices can also be categorized based on the direction of the light emission. In one type referred to as "top emission" type, OLED devices emit light and display images through the cathode or top electrode **1006**. In these embodiments, the cathode **1006** is made of a material transparent or at least partially transparent with respect to visible light. In certain embodiments, to avoid losing any light that can pass through the anode or bottom electrode **1004**, the anode may be made of a material substantially reflective of the visible light. A second type of OLED devices emits light through the anode or bottom electrode **1004** and is called "bottom emission" type. In the bottom emission type OLED devices, the anode **1004** is made of a material which is at least partially transparent with respect to visible light. Often, in bottom emission type OLED devices, the cathode **1006** is made of a material substantially reflective of the visible light. A third type of OLED devices emits light in two directions, e.g. through both anode **1004** and cathode **1006**. Depending upon the direction(s) of the light emission, the substrate may be formed of a material which is transparent, opaque or reflective of visible light.

In many embodiments, an OLED pixel array **1021** comprising a plurality of organic light emitting pixels is arranged over a substrate **1002** as shown in FIG. 7C. In embodiments, the pixels in the array **1021** are controlled to be turned on and off by a driving circuit (not shown), and the plurality of the pixels as a whole displays information or image on the array **1021**. In certain embodiments, the OLED pixel array **1021** is arranged with respect to other components, such as drive and control electronics to define a display region and a non-display region. In these embodiments, the display region refers to the area of the substrate **1002** where OLED pixel array **1021** is formed. The non-display region refers to the remaining areas of the substrate **1002**. In embodiments, the non-display region can contain logic and/or power supply circuitry. It will be understood that there will be at least portions of control/drive circuit elements arranged within the display region. For example, in PMOLEDs, conductive components will extend into the display region to provide appropriate potential to the anode and cathodes. In AMOLEDs, local driving circuits and data/scan lines coupled with the

driving circuits will extend into the display region to drive and control the individual pixels of the AMOLEDs.

One design and fabrication consideration in OLED devices is that certain organic material layers of OLED devices can suffer damage or accelerated deterioration from exposure to water, oxygen or other harmful gases. Accordingly, it is generally understood that OLED devices be sealed or encapsulated to inhibit exposure to moisture and oxygen or other harmful gases found in a manufacturing or operational environment. FIG. 7D schematically illustrates a cross-section of an encapsulated OLED device **1011** having a layout of FIG. 7C and taken along the line d-d of FIG. 7C. In this embodiment, a generally planar top plate or substrate **1061** engages with a seal **1071** which further engages with a bottom plate or substrate **1002** to enclose or encapsulate the OLED pixel array **1021**. In other embodiments, one or more layers are formed on the top plate **1061** or bottom plate **1002**, and the seal **1071** is coupled with the bottom or top substrate **1002**, **1061** via such a layer. In the illustrated embodiment, the seal **1071** extends along the periphery of the OLED pixel array **1021** or the bottom or top plate **1002**, **1061**.

In embodiments, the seal **1071** is made of a frit material as will be further discussed below. In various embodiments, the top and bottom plates **1061**, **1002** comprise materials such as plastics, glass and/or metal foils which can provide a barrier to passage of oxygen and/or water to thereby protect the OLED pixel array **1021** from exposure to these substances. In embodiments, at least one of the top plate **1061** and the bottom plate **1002** are formed of a substantially transparent material.

To lengthen the life time of OLED devices **1011**, it is generally desired that seal **1071** and the top and bottom plates **1061**, **1002** provide a substantially non-permeable seal to oxygen and water vapor and provide a substantially hermetically enclosed space **1081**. In certain applications, it is indicated that the seal **1071** of a frit material in combination with the top and bottom plates **1061**, **1002** provide a barrier to oxygen of less than approximately 10^{-3} cc/m²-day and to water of less than 10^{-6} g/m²-day. Given that some oxygen and moisture can permeate into the enclosed space **1081**, in some embodiments, a material that can take up oxygen and/or moisture is formed within the enclosed space **1081**.

The seal **1071** has a width W, which is its thickness in a direction parallel to a surface of the top or bottom substrate **1061**, **1002** as shown in FIG. 7D. The width varies among embodiments and ranges from about 300 μ m to about 3000 μ m, optionally such as from about 500 μ m to about 1500 μ m. Also, the width may vary at different positions of the seal **1071**. In some embodiments, the width of the seal **1071** may be the largest where the seal **1071** contacts one of the bottom and top substrate **1002**, **1061** or a layer formed thereon. The width may be the smallest where the seal **1071** contacts the other. The width variation in a single cross-section of the seal **1071** relates to the cross-sectional shape of the seal **1071** and other design parameters.

The seal **1071** has a height H, which is its thickness in a direction perpendicular to a surface of the top or bottom substrate **1061**, **1002** as shown in FIG. 7D. The height varies among embodiments and ranges from about 2 μ m to about 30 μ m, optionally from about 10 μ m to about 15 μ m. Generally, the height does not significantly vary at different positions of the seal **1071**. However, in certain embodiments, the height of the seal **1071** may vary at different positions thereof.

In the illustrated embodiment, the seal **1071** has a generally rectangular cross-section. In other embodiments, however, the seal **1071** can have other various cross-sectional shapes such as a generally square cross-section, a generally trapezoid-

dal cross-section, a cross-section with one or more rounded edges, or other configuration as indicated by the needs of a given application. To improve hermeticity, it is generally desired to increase the interfacial area where the seal **1071** directly contacts the bottom or top substrate **1002**, **1061** or a layer formed thereon. In some embodiments, the shape of the seal can be designed such that the interfacial area can be increased.

The seal **1071** can be arranged immediately adjacent the OLED array **1021**, and in other embodiments, the seal **1071** is spaced some distance from the OLED array **1021**. In certain embodiments, the seal **1071** comprises generally linear segments that are connected together to surround the OLED array **1021**. Such linear segments of the seal **1071** can extend, in certain embodiments, generally parallel to respective boundaries of the OLED array **1021**. In other embodiment, one or more of the linear segments of the seal **1071** are arranged in a non-parallel relationship with respective boundaries of the OLED array **1021**. In yet other embodiments, at least part of the seal **1071** extends between the top plate **1061** and bottom plate **1002** in a curvilinear manner.

As noted above, in certain embodiments, the seal **1071** is formed using a fit material or simply "frit" or "glass frit," which includes fine glass particles. The frit particles includes one or more of magnesium oxide (MgO), calcium oxide (CaO), barium oxide (BaO), lithium oxide (Li₂O), sodium oxide (Na₂O), potassium oxide (K₂O), boron oxide (B₂O₃), vanadium oxide (V₂O₅), zinc oxide (ZnO), tellurium oxide (TeO₂), aluminum oxide (Al₂O₃), silicon dioxide (SiO₂), lead oxide (PbO), tin oxide (SnO), phosphorous oxide (P₂O₅), ruthenium oxide (Ru₂O), rubidium oxide (Rb₂O), rhodium oxide (Rh₂O), ferrite oxide (Fe₂O₃), copper oxide (CuO), titanium oxide (TiO₂), tungsten oxide (WO₃), bismuth oxide (Bi₂O₃), antimony oxide (Sb₂O₃), lead-borate glass, tin-phosphate glass, vanadate glass, and borosilicate, etc. In embodiments, these particles range in size from about 2 μ m to about 30 μ m, optionally about 5 μ m to about 10 μ m, although not limited only thereto. The particles can be as large as about the distance between the top and bottom substrates **1061**, **1002** or any layers formed on these substrates where the frit seal **1071** contacts.

The frit material used to form the seal **1071** can also include one or more filler or additive materials. The filler or additive materials can be provided to adjust an overall thermal expansion characteristic of the seal **1071** and/or to adjust the absorption characteristics of the seal **1071** for selected frequencies of incident radiant energy. The filler or additive material(s) can also include inversion and/or additive fillers to adjust a coefficient of thermal expansion of the frit. For example, the filler or additive materials can include transition metals, such as chromium (Cr), iron (Fe), manganese (Mn), cobalt (Co), copper (Cu), and/or vanadium. Additional materials for the filler or additives include ZnSiO₄, PbTiO₃, ZrO₂, eucryptite.

In embodiments, a frit material as a dry composition contains glass particles from about 20 to 90 about wt %, and the remaining includes fillers and/or additives. In some embodiments, the frit paste contains about 10-30 wt % organic materials and about 70-90% inorganic materials. In some embodiments, the frit paste contains about 20 wt % organic materials and about 80 wt % inorganic materials. In some embodiments, the organic materials may include about 0-30 wt % binder(s) and about 70-100 wt % solvent(s). In some embodiments, about 10 wt % is binder(s) and about 90 wt % is solvent(s) among the organic materials. In some embodiments, the inorganic materials may include about 0-10 wt % additives, about 20-40 wt % fillers and about 50-80 wt % glass

powder. In some embodiments, about 0-5 wt % is additive(s), about 25-30 wt % is filler(s) and about 65-75 wt % is the glass powder among the inorganic materials.

In forming a frit seal, a liquid material is added to the dry frit material to form a frit paste. Any organic or inorganic solvent with or without additives can be used as the liquid material. In embodiments, the solvent includes one or more organic compounds. For example, applicable organic compounds are ethyl cellulose, nitro cellulose, hydroxyl propyl cellulose, butyl carbitol acetate, terpineol, butyl cellusolve, acrylate compounds. Then, the thus formed frit paste can be applied to form a shape of the seal **1071** on the top and/or bottom plate **1061**, **1002**.

In one exemplary embodiment, a shape of the seal **1071** is initially formed from the frit paste and interposed between the top plate **1061** and the bottom plate **1002**. The seal **1071** can in certain embodiments be pre-cured or pre-sintered to one of the top plate and bottom plate **1061**, **1002**. Following assembly of the top plate **1061** and the bottom plate **1002** with the seal **1071** interposed therebetween, portions of the seal **1071** are selectively heated such that the frit material forming the seal **1071** at least partially melts. The seal **1071** is then allowed to resolidify to form a secure joint between the top plate **1061** and the bottom plate **1002** to thereby inhibit exposure of the enclosed OLED pixel array **1021** to oxygen or water.

In embodiments, the selective heating of the frit seal is carried out by irradiation of light, such as a laser or directed infrared lamp. As previously noted, the frit material forming the seal **1071** can be combined with one or more additives or filler such as species selected for improved absorption of the irradiated light to facilitate heating and melting of the frit material to form the seal **1071**.

In some embodiments, OLED devices **1011** are mass produced. In an embodiment illustrated in FIG. 7E, a plurality of separate OLED arrays **1021** is formed on a common bottom substrate **1101**. In the illustrated embodiment, each OLED array **1021** is surrounded by a shaped frit to form the seal **1071**. In embodiments, common top substrate (not shown) is placed over the common bottom substrate **1101** and the structures formed thereon such that the OLED arrays **1021** and the shaped frit paste are interposed between the common bottom substrate **1101** and the common top substrate. The OLED arrays **1021** are encapsulated and sealed, such as via the previously described enclosure process for a single OLED display device. The resulting product includes a plurality of OLED devices kept together by the common bottom and top substrates. Then, the resulting product is cut into a plurality of pieces, each of which constitutes an OLED device **1011** of FIG. 7D. In certain embodiments, the individual OLED devices **1011** then further undergo additional packaging operations to further improve the sealing formed by the frit seal **1071** and the top and bottom substrates **1061**, **1002**.

FIG. 1 is a cross-sectional view of an organic light-emitting display device. The display device of FIG. 1 is a dual view type of organic light-emitting display device having two pixel regions emitting light in different directions (e.g., a forward facing display region and a backward facing display region).

Referring to FIG. 1, an organic light-emitting display device is configured including a first substrate **10** and a second substrate **20** positioned to be opposed to each other, and the first and the second substrates **10** and **20** are adhered to each other with encapsulating material **30** and the inner side thereof is thus encapsulated.

The first substrate **10** comprises a first pixel region **11** and a second pixel region **12** and a non-pixel region. The first and the second pixel regions **11** and **12** are provided with a plu-

rality of pixels having at least one organic light-emitting diode (not shown). The non-pixel region is provided with a driving circuit comprising a first scan driver **13** and a second scan driver **14**. In this example, the first pixel region **11** is a top emission type pixel region emitting light through the second substrate **20**, and the second pixel region **12** is a bottom emission type pixel region emitting light through the first substrate **10**. The first scan driver **13** supplies a scan signal to the first pixel region **11**, and the second scan driver **14** supplies a scan signal to the second pixel region **12**. Thus, the display device shown in FIG. 1 is capable of displaying in two directions, forward and backward in this example.

The second substrate **20** is adhered the first substrate **10** on which the first and the second pixel regions **11** and **12** are formed. The second substrate **20** is adhered to the first substrate **10** such that at least one region of the first substrate **10**, in particular, the first and the second pixel regions **11** and **12** is encapsulated between the first substrate **10**, the second substrate **20** and the encapsulating material **30**. In this example, a light shielding film is formed on an outer side of the second substrate **20** located above the second pixel region **12** for preventing a transmission of external light or light leakage. A black tape, etc. can be used as the light shielding film **22**. In other embodiments, where the light shielding film **22** is not provided, a back side of the pixel region **12** facing the second substrate **20** can be made to be opaque.

The encapsulating material **30**, such as an epoxy resin, is applied along the edge of the first substrate **10** and the second substrate **20**. The encapsulating material is melted, e.g., by irradiation of ultraviolet rays, etc. and is thus cured, adhering the first substrate **10** to the second substrate **20**. The encapsulating material **30** is used to prevent the infiltration of oxygen and moisture, etc. into the region between the first substrate **10** and the second substrate **20** containing the first and the second pixel regions **11** and **12**.

However, even though the encapsulating material **30** is applied, the infiltration of oxygen and moisture, etc. through fine cracks in the encapsulating material and/or the substrates cannot be completely blocked. In order to prevent this, in the prior art moisture absorbent material (not shown), etc., can be coated on the second substrate **20** and then burned. However, the adhesion between the encapsulating material **30** and the substrates **10** and **20** can be deteriorated due to outgassing generated when the moisture absorbent material is burned, causing a problem that the first and the second pixel regions **11** and **12** are easily exposed to oxygen and moisture.

U.S. Patent Laid-Open Publication No. 2004-0207314 discloses a structure to encapsulate at least one region including the first and the second pixel regions **11** and **12** of the first substrate **10** by applying a frit to a glass substrate without having moisture absorbent material applied. According to this patent publication, since the space between the two substrates is completely encapsulated by curing the melted frit, the moisture absorbent material is not needed and thus the first and the second pixel regions **111** and **12** can be more effectively protected.

FIG. 2 is a plan view showing an organic light-emitting display device according to an embodiment. FIG. 3 is a cross-sectional view of main parts of a pixel contained in the display device shown in FIG. 2. FIG. 2 shows a double side emission type active matrix organic light-emitting display device. Each pixel is provided with at least one thin film transistor and an organic light-emitting diode, however, the present invention is not limited thereto.

Referring to FIG. 2 and FIG. 3, an organic light-emitting display device, according to an embodiment, comprises: a first substrate **100**; a second substrate **200** disposed over the

first substrate **100** to be overlapped with at least one region of the first substrate **100**. A frit **300** is applied to at least one region between the first substrate **100** and the second substrate **200** and the first and the second substrates **100** and **200** are adhered to each other by means of at least a portion of the applied frit **300**.

On the first substrate **100**, a first pixel region **105** and a second pixel region **106** each comprise a plurality of pixels **110**. A first scan driver **120** and a first data driver **130** for supplying a driving signal to the first pixel region **105** are formed on the substrate **100**. A second scan driver **121** and a second data driver **131** for supplying a driving signal to the second pixel region **106** are also formed on the first substrate **100**. A pad region **102** comprising a plurality of electrically conductive pads for supplying control signals to the first and the second scan drivers **120** and **121** and to the first and the second data drivers **130** and **131** is formed on the first substrate **100**.

The first and the second pixel regions **105** and **106** include at least the regions where scan lines (S1 to Sn and S1' to Sn') arranged in a row direction intersect data lines (D1 to Dm and D1' to Dm') arranged in a column direction. A plurality of pixels **110**, positioned at points where the scan lines (S1 to Sn and S1' to Sn') intersect with the data lines (D1 to Dm and D1' to Dm') are formed in the first and second pixel regions **105** and **106**. The respective pixels **110** generate light having predetermined brightness corresponding to the scan signal supplied to the scan lines (S1 to Sn and S1' to Sn') and the data signal supplied to the data lines (D1 to Dm and D1' to Dm'). Thereby, a predetermined image (or images) is displayed on the first and the second pixel regions **105** and **106**. In this example, the first pixel region **105** is a top emission type pixel region emitting light in the direction of and through the second substrate **200**, and the second pixel region **106** is a bottom emission type pixel region emitting light in the opposite direction and through the first substrate **100**. That is, the organic light-emitting display device according to the present embodiment provides a double sided emission type organic light-emitting display device. Thus, an image is displayed on the front and the rear thereof. To this end, the first and the second substrate **100** and **200** are made of transparent materials.

Each pixel **110** included in the first and the second pixel region **105** and **106** includes an organic light-emitting diode **118**. The light-emitting diode **118** is a light emission element, and at least one thin film transistor is connected to the organic light-emitting diode **118**, as shown in FIG. 3. However, the structure of the pixel **110** can be modified in various ways and can be included in an active matrix organic light-emitting display device or a passive matrix organic light-emitting display device.

The thin film transistor comprises a buffer layer **111** formed on the first substrate **100**, a semiconductor layer **112** formed on the buffer layer **111** and including a channel region **112a** and source and drain regions **112b**, a gate insulating film **113** formed on the semiconductor layer **112**, a gate electrode **114** formed on the gate insulating film **113**, an interlayer insulating film **115** formed on the gate electrode **114**, and source and drain electrodes **116** formed on the interlayer insulating film **115** and connected to the source and drain regions **112b**.

A planarization film **117** having a via hole **117a** exposing at least one region of the drain electrode **116** is formed over the interlayer insulating film **115** and the source and drain electrodes **116**. The organic light-emitting diode **118** connected to the thin film transistor through the via hole **117a** is formed over the planarization layer **117**. The organic light-emitting

diode **118** comprises a first electrode **118a**, a second electrode **118c**, and an organic light-emitting layer **118b** positioned therebetween. The first electrode **118a** is formed on the planarization film **117** and is connected to the drain electrode of the thin film transistor through the via hole **117a**. In the case of a pixel configured to emit light from its top, such as a pixel located in the first pixel region **105**, the first electrode **118a** can further be provided with a reflective film for improving light efficiency of reflecting light through the second substrate **200**. A pixel defining film **119** is formed over the first electrode **118a** having an opening portion exposing at least a part of the first electrode **118a**. The organic light-emitting layer **118b** is formed in the opening portion of the pixel defining film **119**. The second electrode **118c** is formed over the organic light emitting layer **118b**. In the case of the pixel **110** being configured to emit light from the rear thereof, such as in the case of a pixel included in the second pixel region **106**, the second electrode **118c** can further be provided with a reflective film for improving the efficiency of reflecting the emitted light through the first substrate **100**. A passivation layer, as well as other layers, which are not shown, can further be formed over the second electrode **118c**. The organic light-emitting diode **118** as described above generates light having predetermined brightness corresponding to the current level supplied from the thin film transistor.

First and second scan drivers **120** and **121**, first and second data drivers **130** and **131**, and a pad region **102** are formed in a non-pixel region around the first and the second pixel regions **105** and **106**. The first and the second scan drivers **120** and **121** generate scan signals corresponding to the control signals supplied from electrically conductive pads (e.g., supplied by an external signal source) in the pad region **102** and supply them to the scan lines (S1 to Sn) of the first pixel region **105** and the scan lines (S1' to Sn') of the second pixel region **106**, respectively. The first and the second data drivers **130** and **131** generate data signals corresponding to data and control signals supplied from the electrically conductive pads (e.g., supplied by an external data source) in the pad region **102**, and supply them to data lines (D1 to Dm) of the first pixel region **105** and the data lines (D1' to Dm') of the second pixel region **106**, respectively. The pad region **102** supplies the control signals supplied from an external source to the first and the second scan drivers **120** and **121** and the first and the second data drivers **130** and **131**.

The second substrate **200** positioned over the upper part of the first substrate **100** so as to overlap at least the first and the second pixel regions **105** and **106**. The pixels **110** formed on the first substrate **100** include the organic light-emitting layer **118a** and therefore can be adversely affected when oxygen and moisture infiltrate the area between the first and second substrates **100** and **200**. Therefore, in order to prevent an infiltration of oxygen and moisture into the first and the second pixel regions **105** and **106** in which pixels **110** are formed, the second substrate **200** is adhered to the first substrate by at least a portion of the frit **300** surrounding the first and the second pixel regions **105** and **106**. In the embodiment shown in FIG. 2, the second substrate **200** is also configured to encapsulate the first and the second scan drivers **120** and **121**, however, the present invention is not limited thereto. That is, the second substrate **200** is positioned over the upper part of the first substrate **100** so as to overlap at least a part of the first substrate **100**, including the first and the second pixel regions **105** and **106**, and is then adhered to the first substrate **100** by means of at least a portion of the frit **300**. As discussed above in reference to FIG. 1, some organic light emitting displays include an opaque layer or a black matrix layer such as the light shielding film **22** formed over a portion of the second

substrate 200 located over the second pixel region 106. The light shielding film 22 prevents light emitted from the second pixel region 105 from being emitted through or reflected off of the second substrate 200, where the second pixel region 105 is configured to emit light through the first substrate 100. However, in other embodiments the second substrate 200 may comprise a transparent material. In these other embodiments, the frit 300 is a non-transparent material (e.g., a black tint) and is applied to the inner side of the second substrate 200 facing the second pixel region 106, and therefore the frit 300 functions as an adhesive material as well serving as the black matrix to prevent light emitted from the second pixel from reflecting off of or transmitting through the second substrate 200. Preferably, the frit 300, comprises material including a transition metal, tinted black for preventing light from being passed through or reflecting off of the second substrate 200, thereby functioning as the black matrix (BM) preventing the light leakage.

A frit seal portion of the frit 300 can be applied to portions of the first and the second substrates 100 and 200 and then bonded together in order to completely adhere the first and the second substrates 100 and 200 to each other. Another portion of the frit 300 can be applied to overlap with the inner side of the second substrate in an area facing the second pixel region 106. Accordingly, the inner portion of the fit 300 overlaps with the second pixel region 106, the inner portion functions as a black matrix blocking light generated in the second pixel region 106 not permitting it to be emitted from the second pixel region 106 and transmitted through or reflected off of the second substrate 200. An additional black matrix layer dedicated to blocking light is not needed, thereby, simplifying the process as well as effectively preventing the light leakage. However, since the first pixel region 105 should emit light from the top and through the second substrate 200, the fit 300 is formed so as not to be positioned above the first pixel region 105. By forming the frit seal portion of the fit 300 on the circumferential portion surrounding the first pixel region 105, for example, so as to include the first scan driver 120, light leakage generated from the first pixel region 105 can be effectively blocked from entering into the regions outside of the circumference of the first pixel region 105. That is, the frit 300 is formed to be positioned on the second substrate in regions other than the first pixel region 105 and configured to surround at least the first pixel region 105, thereby effectively preventing light leakage.

The frit 300 can comprise raw glass material and one or more additives in the form of a powder. Alternatively, the frit 300 can be in a solidified state after being melted and then being permitted to solidify. In this example, the frit seal portion of the frit 300 is adhered to the first and the second substrate 100 and 200 so as to completely surround the space including the first and second pixel regions 105 and 106 (and the scan drivers 120 and 121) between the first and the second substrates 100 and 200. The frits seal portions located in the non-pixel region and configured to surround the first and second pixel regions 105 and 106 are melted by laser or infrared rays and are allowed to resolidify, thereby effectively encapsulating the first and second pixel regions in an enclosed space and blocking an infiltration of oxygen and moisture into the enclosed space. However, only the frit seal portion of the frit 300 located in the non-pixel region surrounding the display elements including the second pixel region 105 and 106 and the first and the second scan drivers 120 and 121 is used to adhere the first and the second substrates 100 and 200. A detailed explanation of a method of encapsulating the first and second pixel areas 105 and 106 by applying the frit 300 will be described below in reference to FIGS. 6A to 6D.

FIG. 4 is a cross-sectional view of an organic light-emitting display device taken along A-A' line in FIG. 2. The first pixel region 105 formed on the first substrate 100 emits light in the direction of the second substrate 200, and the second pixel region 106 emits light in the opposite direction toward the first substrate 100. The first and the second pixel regions 105 and 106 as discussed above are enclosed in a space defined by the first and second substrates 100 and 200 and the frit 300. Here, the frit 300 comprises a material that is non-transparent to visible light (e.g., tinted with a black color) and is positioned on the inner surface of the second substrate 200 in an area opposing the second pixel region 106, thereby effectively blocking the light leakage. However, a peripheral frit seal portion of the frit 300 is formed to be thicker than the inner frit 300 and is configured to surround both the first and the second pixel regions 105 and 106 (see FIG. 4).

In some embodiments, the frit 300 comprises a glass material, an additive or filler material for adjusting the absorption characteristics, and an additive or filler material for adjusting the thermal expansion coefficient of the frit 300. The frit material can be applied to the second substrate 200 in the form of a paste and subsequently melted, e.g., by laser or infrared rays, and allowed to resolidify between the first and the second substrates 100 and 200, thereby adhering the first substrate 100 to the second substrate 200. During the irradiation process, if laser or infrared rays are irradiated to the frit 300 positioned in areas in proximity of the first and/or the second pixel regions 105 and 106 and the first and the second scan drivers 120 and 121, the internal circuits of the first and the second pixel regions 105 and 106 and the first and the second scan drivers 120 and 121 can be damaged. Therefore, the laser or infrared rays should be irradiated to only the frit 300 applied to the portion of the substrates in which these elements are not formed, e.g., by using a mask, etc. That is, by irradiating laser or infrared rays along the edge of the frit 300 in which the second pixel regions 105 and 106 and the first and the second scan drivers 120 and 121 are not formed, the frit 300 adheres and encapsulates the first and the second substrates 100 and 200. The frit 300 positioned along the edges of the non-pixel region absorbing laser or infrared rays is melted and allowed to resolidify, thereby enclosing the first and second pixel regions 105 and 106 between the first and the second substrates 100 and 200 and the frit 300. However, the frit 300 applied to the region in which the second pixel region and 106 and the first and the second scan drivers 120 and 121 are formed is not irradiated and thereby not adhered to the second pixel region 106 and the first and the second scan drivers 120 and 121 where the frit 300 is not functioning as a source of adhesion but functions only as the black matrix preventing the light leakage.

The example shown in FIG. 4 shows the second substrate 200 as a flat panel, however, the second substrate 200 can also include an inner etched portion wherein the thickness of the inner portion is thinner than that of an outer edge portion surrounding the inner etched portion. In this case, the frit 300 can be formed over the entire inner side of the second substrate 200 (except in the portion located across from the first pixel region 105) in the same thickness. For example, the frit seal portion of the frit 300 surrounding the first and second pixel regions 105 and 106 and the first and second scan drivers 120 and 121, and the inner frit portion facing the second pixel region 106 can be formed in the same thickness. FIG. 5 shows a cross sectional view of an organic light-emitting display device including an etched second substrate 200'. Since the etched second substrate 200' has a thinner inner portion in the region across from the pixel region 105 and the scan drivers 120 and 120', the frit 300 can be applied in the same thickness

across the second substrate **200'**. The outer edge of the frit **300** will then be the only portion bonding the first substrate **100** and the second substrate **200'**.

FIG. **6a** to FIG. **6d** are cross-sectional views showing various stages in a process of fabricating the organic light-emitting display device shown in FIG. **4**. Referring to FIG. **6a** to FIG. **6d**, a method of fabricating the organic light-emitting display device shown in FIG. **4** will be described in detail. For convenience, although FIG. **6a** to FIG. **6d** show the method for fabricating the individual organic light-emitting display device, in fact a plurality of display device cells can be fabricated in a sheet unit and subsequently cut into individual display devices.

Referring to FIG. **6a**, first the frit **300** is applied to the inner side of the second substrate **200** facing the first substrate **100**. The frit **300** is applied in an inner portion of the substrate **200** facing the second pixel region **106** and a frit seal portion is formed in the non-pixel region surrounding the first and second pixel regions **105** and **106**. A frit layer is not formed on the inner side of the second substrate in the area of the first pixel region **105** in order to allow light emitted from the first pixel region **105** to pass through the second substrate **200**. The frit seal portion of the frit **300** in the region surrounding at least one of the non-pixel regions **105** or **106**, that is, the edge part in which no display elements are formed, is made to be thicker than the inner portion of the frit **300** to be overlapped with the second pixel region **106** and the first and second scan drivers **120** and **121**. The frit **300** is applied to the second substrate **200** in a paste state and may include an additive or filler to adjust the absorption characteristics of the seal for selected frequencies of incident radiant energy including absorbent laser or infrared rays. The paste is then melted and allowed to resolidify after moisture or organic binder material included in the paste is removed. The frit paste can be transformed into a gel state by adding oxide powder and organic substance to the glass powder, increasing the temperature of the frit paste **300** preferably to a range from about 300° C. to about 500° C. It is preferable that the thickness of the frit **300** be from about 10 μm to about 20 μm. If the frit seal is about 20 μm or more, a large amount of energy may be required at the time of sealing with laser so that the power of laser needed to melt the frit may be excessively high, or the scan speed of the laser may be excessively slow, resulting in possible heat damage to the frit, the substrates, and/or the display elements. If the frit seal is about 10 μm or less, defects due to unequal deposition of the frit material may occur at an unacceptable rate.

In one embodiment, the first substrate **100** comprising the first and the second pixel regions **105** and **106** and the first and the second scan drivers **120** and **121** is provided as an unfinished product. The unfinished device formed on the first substrate **100** is placed over the second substrate **200**. The first substrate **100** and the second substrate **200** are bonded to each other by the frit **300** so that the first and the second pixel regions **105** and **106** are encapsulated in a space defined by the first and second substrates **100** and **200** and the frit **300**. At this time, the frit **300** is positioned between the first and the second substrates **100** and **200**.

After positioning the first and second substrates as shown in FIG. **5b**, laser or infrared rays are irradiated to the frit **300** in the frit seal positioned in the outer region of the substrates in which no elements subject to damage by irradiation are formed, as shown in FIG. **6c**. The frit seal portion of the frit **300**, to which laser or infrared rays are irradiated, is melted by absorption of the energy in the laser or infrared rays. Preferably, the wavelength of laser or infrared rays is in a range from about 800 nm to about 1200 nm (more preferably, about 810 nm). Preferably, the beam size is configured to be from about

1.0 nm to about 3.0 nm in diameter, and the output electric power is configured to be from about 25 watt to about 45 watt. The portions of the substrates to which laser or infrared rays are not to be irradiated can be masked. That is, the wirings (not shown) positioned between the first and the second pixel regions **105** and **106** and the first and the second scan drivers **120** and **121** can be masked so as not to be irradiated by laser or infrared rays. In this way, the wirings and the elements that are susceptible to damage by the irradiation may be prevented from being adversely affected by the laser or infrared rays. In one embodiment, a mask comprising a double film of copper and aluminum can be used.

The irradiation of the frit **300** melts the outer frit seal portion surrounding the pixel region **105** containing the array of organic light-emitting pixels. The frit seal is then allowed to resolidify thereby adhering the first substrate **100** to the second substrate **200** with the outer frit seal portion only. The inner frit layer serving as the black mask is substantially unaffected by the irradiation process since it was masked from the irradiation beam.

Although the example process discussed in reference to FIGS. **6a** to **6d** comprises forming the frit on the second substrate **200**, the process is not limited thereto. For example, the frit **300** can first be applied to the first substrate **100** on which the first and the second pixel regions **105** and **106** are formed, or can be applied to both the first and the second substrates **100** and **200**, adhering the first and the second substrates **100** and **200**. Also, when the second substrate **200** is configured to be an etched glass as shown in FIG. **5**, the frit **300** can be applied to the second substrate **200** in the same thickness. This may further simplify the step of forming the frit **300** including the inner portion serving as the black matrix for the second pixel region **106**, and the outer portion serving as the frit seal.

In the organic light-emitting display device and the method for fabricating the same as described above, the first and the second substrates **100** and **200** are adhered by means of the frit **300**, resulting in that the infiltration of oxygen and moisture, etc. into the internal space including the first and the second pixel regions **105** and **106** can be effectively blocked. Also, in the double side emission type organic light-emitting display device comprising the first pixel region **105** emitting light to the top and the second pixel region **106** emitting light to the rear, the frit **300** tinted black can be formed on an inner side of the second substrate **200** in proximity of the second pixel region **106**, and formed in the non-pixel region surrounding the first and second substrates **100** and **200**, thereby improving image quality by effectively preventing the light leakage. In this case, since the black matrix of the second pixel region **106** can be formed in the same step as the frit seal for encapsulating the first and the second substrates **100** and **200**, there is no need to make the second substrate **200** partially opaque or to form the light shielding film thereon in a second step. Thus, simplifying the fabrication process and reducing the processing time thereof. The regions of the frit located in proximity of the parts in which display elements are formed, such as the first and the second pixel regions **105** and **106** and the first and the second scan drivers **120** and **121**, are masked and thus not irradiated by laser or infrared rays. Only the outer frit seal portion of the frit **300** is irradiated by laser or infrared rays, thereby preventing damage to the display elements.

As described above, according to the organic light-emitting display device and the method for fabricating the same, the first and the second substrates are adhered by means of the frit **300**, resulting in that the infiltration of oxygen and moisture, etc. into the internal space including the pixel regions

can be effectively blocked. Also, in the double side emission type organic light-emitting display device comprising the first pixel region emitting light from the top and the second pixel region emitting light from the rear, the frit tinted black can be formed to be overlapped with the second pixel region and the non-pixel region surrounding the first and second pixel regions, thereby improving image quality by effectively preventing the light leakage. In this case, the black matrix can be formed while forming a frit seal for encapsulating the first and the second substrates, simplifying the process thereof and reducing the process time thereof.

Although a few embodiments of the present invention have been shown and described, it would be appreciated by those skilled in the art that changes might be made in this embodiment without departing from the principles and spirit of the invention, the scope of which is defined in the claims and their equivalents.

What is claimed is:

1. An organic light-emitting device comprising:
 - a first substrate;
 - a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion;
 - a first array of light-emitting pixels interposed between the first substrate and the second substrate, said first array configured to emit light in at least a first direction;
 - a second array of light-emitting pixels interposed between the first substrate and the second substrate, said second array configured to emit light in at least a second direction;
 - a frit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface so as to block light scattered toward the second direction, wherein the first portion generally opposes the first array and the second portion generally opposes the second array; and
 - a frit seal interconnecting the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.
2. The device of claim 1, wherein the pixels of the first array are configured to emit light substantially through the first substrate.
3. The device of claim 1, wherein the pixels of the second array are configured to emit light substantially through the second substrate.
4. The device of claim 3, wherein the first portion of the inner surface extends over the entire first array.
5. The device of claim 1, wherein a portion of the frit seal is adhered to the first substrate and the second substrate.
6. The device of claim 1, wherein the frit comprises a glass material, and at least one of a filler material to adjust absorption characteristics, and a filler material to adjust thermal expansion characteristics.
7. The device of claim 1, wherein the first substrate and the second substrate are transparent substrates.
8. The device of claim 1, wherein the frit layer comprises a material that is non-transparent to visible light.
9. The device of claim 1, wherein the first array is enclosed inside a first pixel area consisting of pixels configured to emit light in the first direction, and the second array is enclosed inside a second pixel area consisting of pixels configured to emit light in the second direction.
10. The device of claim 1, wherein the frit layer is a continuous single layer.

11. The device of claim 1, wherein the first substrate comprises a first display area on one side of the device, and the second substrate comprising a second display area on an opposite side of the device.

12. An organic light-emitting device comprising:
 - a first substrate;
 - a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion, wherein a thickness of the second substrate in an inner portion comprising the first portion and the second portion is thinner than in an outer portion surrounding the inner portion;
 - a first array of light-emitting pixels interposed between the first substrate and the second substrate, said first array configured to emit light in at least a first direction;
 - a second array of light-emitting pixels interposed between the first substrate and the second substrate, said second array configured to emit light in at least a second direction;
 - a fit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface so as to block light scattered toward the second direction, wherein the first portion generally opposes the first array and the second portion generally opposes the second array; and
 - a fit seal formed over the outer portion interconnecting the first and second substrates while surrounding the first array and the second array such that the fit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.

13. The device of claim 12, wherein the frit layer formed over the first portion of the inner surface and the fit seal formed over the outer portion have substantially same thickness.

14. The device of claim 12, wherein the first portion of the inner surface extends over the entire first array.

15. A method of making an organic light-emitting device, the method comprising:

- providing an unfinished device comprising a first substrate, wherein a first array of organic light emitting pixels and a second array of light emitting pixels are formed on the first substrate;
- providing a second substrate, wherein the second substrate comprises a surface comprising a first portion and a second portion;
- forming a frit layer over the first portion of the surface of the second substrate while not being formed over the second portion of the surface;
- forming a peripheral fit on around edges of the second substrate;
- placing the second substrate over the unfinished device such that the first substrate, the second substrate, and the peripheral frit form an enclosed space therein, wherein the first array and the second array are located in the enclosed space and the first portion generally extends over the first array and the second portion generally extends over the second array so as to block at least some of light scatter toward the first portion; and
- melting and re-solidifying at least part of the peripheral frit so as to interconnect the unfinished device and the second substrate via the peripheral frit.

16. The method of claim 15, wherein the peripheral frit is thicker than the frit layer formed over the first portion.

17. The method of claim 15, wherein melting the peripheral frit comprises irradiating by laser or infrared rays.

19

18. The method of claim **17**, wherein the wavelength of the laser or the infrared rays are in a range from about 800 nm to about 1200 nm.

19. The method of claim **17**, further comprising masking at least the first portion and the second portion while irradiating. 5

20. The method of claim **15**, the method further comprising heating the peripheral frit to a temperature sufficient to cure the peripheral frit, wherein the peripheral frit is applied to at least one of the first substrate and the second substrate in form of a paste comprising a glass material and a filler material to adjust absorption characteristics of laser or infrared rays. 10

20

21. The method of claim **20**, wherein heating the peripheral frit comprises irradiating with laser or infrared rays.

22. The method of claim **20**, wherein the peripheral frit is heated to a temperature in a range from about 300° C. to about 500° C.

23. The method of claim **15**, wherein the first portion of the inner surface extends over the entire first array.

* * * * *

UNITED STATES PATENT AND TRADEMARK OFFICE
CERTIFICATE OF CORRECTION

PATENT NO. : 7,919,920 B2
APPLICATION NO. : 11/644593
DATED : April 5, 2011
INVENTOR(S) : Won Kyu Kwak

Page 1 of 4

It is certified that error appears in the above-identified patent and that said Letters Patent is hereby corrected as shown below:

At Page 1 (Item 57) Abstract, Line 14, Change "fit" to --frit--.

At Column 3, Line 2, Change "fit" to --frit--.

At Column 3, Line 4, Change "fit" to --frit--.

At Column 3, Line 7, Change "fit" to --frit--.

At Column 6, Line 18, Change "fight" to --light--.

At Column 7, Line 47, after "um," delete "optionally".

At Column 8, Line 23, Change "fit" to --frit--.

At Column 10, Line 9, Change "1," to --11,--.

At Column 10, Line 55, Change "111" to --11--.

At Column 13, Line 25, Change "fit" to --frit--.

At Column 13, Line 34, Change "fit" to --frit--.

At Column 13, Line 36, Change "fit" to --frit--.

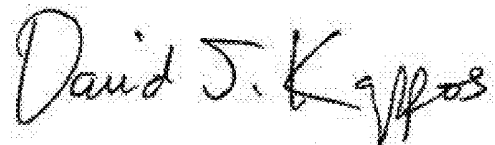
At Column 15, Line 66-67, Change "810 mm)." to --810 nm).--.

At Column 16, Line 10, Change "rays. in" to --rays. In--.

At Column 16, Line 55, Change "fit" to --frit--.

At Column 17, Lines 20-42, In Claim 1, Change "1. An organic light-emitting device comprising: a first substrate; a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion; a first array of light-emitting pixels interposed between the first substrate and the second substrate, said first array configured to emit light in at least a first direction; a second array of light-emitting pixels interposed between the first substrate and the second substrate, said second array configured to emit light in at least a second direction; a frit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface so as to block light scattered toward the second direction, wherein the first portion

Signed and Sealed this
Fifteenth Day of November, 2011



David J. Kappos
Director of the United States Patent and Trademark Office

U.S. Pat. No. 7,919,920 B2

generally opposes the first array and the second portion generally opposes the second array; and a frit seal interconnecting the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.” to --1. An organic light-emitting device comprising: a first substrate; a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion; a first array of light-emitting pixels interposed between the first substrate and the second substrate, said first array configured to emit light in a first direction; a first scan driver and a first data driver configured to supply signals to the first array; a second array of light-emitting pixels interposed between the first substrate and the second substrate, said second array configured to emit light in a second direction; and a second scan driver and a second data driver configured to supply signals to the second array; a frit layer formed over the entire first portion of the inner surface and over the first and second scan drivers, while not formed over the second portion of the inner surface so as to block light scattered toward the second direction, wherein the first portion substantially entirely lies over the first array and the second portion substantially entirely lies over the second array, wherein the frit layer comprises a frit seal extending from the frit layer; wherein the frit seal interconnects the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.--.

At Column 18, Lines 5-32, In Claim 12, Change “12. An organic light-emitting device comprising: a first substrate; a second substrate comprising an inner surface facing the first substrate, the inner surface comprising a first portion and a second portion, wherein a thickness of the second substrate in an inner portion comprising the first portion and the second portion is thinner than in an outer portion surrounding the inner portion; a first array of light-emitting pixels interposed between the first substrate and the second substrate, said first array configured to emit light in at least a first direction; a second array of light-emitting pixels interposed between the first substrate and the second substrate, said second array configured to emit light in at least a second direction; a fit layer formed over the first portion of the inner surface while not formed over the second portion of the inner surface so as to block light scattered toward the second direction, wherein the first portion generally opposes the first array and the second portion generally opposes the second array; and a fit seal formed over the outer portion interconnecting the first and second substrates while surrounding the first array and the second array such that the fit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.” to --12. An organic light-emitting device comprising: a first substrate; a second substrate comprising an inner

U.S. Pat. No. 7,919,920 B2

surface facing the first substrate, the inner surface comprising a first portion and a second portion, wherein a thickness of the second substrate in an inner portion comprising the first portion and the second portion is thinner than in an outer portion surrounding the inner portion; a first array of light-emitting pixels interposed between the first substrate and the second substrate, said first array configured to emit light in a first direction; a first scan driver and a first data driver configured to supply signals to the first array; a second array of light-emitting pixels interposed between the first substrate and the second substrate, said second array configured to emit light in a second direction; a second scan driver and a second data driver configured to supply signals to the second array; a frit layer formed over the entire first portion of the inner surface and over the first and second scan drivers, while not formed over the second portion of the inner surface so as to block light scattered toward the second direction, wherein the first portion substantially entirely lies over the first array and the second portion substantially entirely lies over the second array, wherein the frit layer comprises a frit seal extending from the frit layer; wherein the frit seal is formed over the outer portion and interconnects the first and second substrates while surrounding the first array and the second array such that the frit seal, the first substrate and the second substrate form an enclosed space where the first array and the second array are located.--.

At Column 18, Line 34, In Claim 13, Change "fit" to --frit--.

At Column 18, Lines 39-63, In Claim 15, Change "15. A method of making an organic light-emitting device, the method comprising: providing an unfinished device comprising a first substrate, wherein a first array of organic light emitting pixels and a second array of light emitting pixels are formed on the first substrate; providing a second substrate, wherein the second substrate comprises a surface comprising a first portion and a second portion; forming a frit layer over the first portion of the surface of the second substrate while not being formed over the second portion of the surface; forming a peripheral fit on around edges of the second substrate; placing the second substrate over the unfinished device such that the first substrate, the second substrate, and the peripheral frit form an enclosed space therein, wherein the first array and the second array are located in the enclosed space and the first portion generally extends over the first array and the second portion generally extends over the second array so as to block at least some of light scatter toward the first portion, and melting and re-solidifying at least part of the peripheral frit so as to interconnect the unfinished device and the second substrate via the peripheral frit." to --15. A method of making an organic light-emitting device the method comprising: providing an unfinished device comprising a first substrate, a first array of organic light-emitting pixels formed on the first substrate, a second array of organic light-emitting pixels formed on the second substrate, a first scan driver and a first data

U.S. Pat. No. 7,919,920 B2

driver configured to supply signals to the first array, and a second scan driver and a second data driver configured to supply signals to the second array, wherein the first array emits light in a first direction and the second array emits light in a second direction; providing a second substrate, wherein the second substrate comprises a surface comprising a first portion and a second portion; forming a frit layer over the entire first portion of the surface of the second substrate and over the first and second scan drivers, while not being formed over the second portion of the surface, wherein the frit layer comprises a peripheral frit seal extending from the frit layer;

forming the peripheral frit seal on edges of the second substrate; placing the second substrate over the unfinished device such that the first substrate, the second substrate, and the peripheral frit form an enclosed space therein, wherein the first array and the second array are located in the enclosed space and the first portion substantially entirely extends over the first array and the second portion substantially entirely extends over the second array so as to block at least some of light scatter toward the first portion; and melting and re-solidifying at least part of the peripheral frit so as to interconnect the unfinished device and the second substrate via the peripheral frit.--.

专利名称(译)	有机发光显示装置及其制造方法		
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申请(专利权)人(译)	KWAK WON KYU		
当前申请(专利权)人(译)	三星DISPLAY CO. , LTD.		
[标]发明人	KWAK WON KYU		
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摘要(译)

公开了一种有机发光显示装置，其能够阻挡氧气和水分的渗透并有效地防止漏光。该器件包括具有第一和第二像素区域的第一衬底，其中形成多个有机发光二极管。该器件还包括围绕第一和第二像素区域的非像素区域，设置在第一基板的上部以与第一和第二像素区域重叠的第二基板和玻璃料设置在所述第一和第二基板之间，以与所述第一和第二像素区域中的至少一个以及所述非像素区域的至少一部分重叠。第一和第二基板通过配合在与非像素区域对应的部分中彼此粘附。

